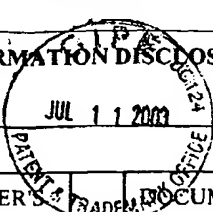
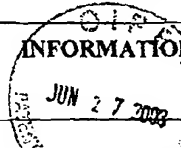


FORM PTO-1449 (REV 7-80)		Atty. Docket No. IR-3569(3055-001-01)		Application No. 09/869,454		
INFORMATION DISCLOSURE STATEMENT 		APPLICANT: AMIN-SANAYEI et al.				
		Filing Date: June 28, 2001		Group Art Unit: 1714		
U.S. PATENT DOCUMENTS						
EXAMINER'S INITIALS	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB-CLASS	FILING DATE, IF APPROPRIATE
<i>WJ</i>	2003/0045626 A1	3/6/03	Tamori et al.	524	547	
FOREIGN PATENT DOCUMENTS						
	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB-CLASS	TRANSLATION YES NO
OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)						
<i>WJ</i>	European Search Report for EP 03 29 0237					
EXAMINER	<i>Tue Y033</i>			DATE CONSIDERED		
			<i>10-28-03</i>			
<p>*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.</p>						

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EXAMINER'S INITIALS	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB-CLASS	FILING DATE, IF APPROPRIATE
267	H0,001,279	1/4/94	Stephenson	524	317	
	2,559,752	7/10/51	Berry	260	29.6	
	3,475,396	10/28/69	McCain et al.	260	92.1	
	3,644,255	2/22/72	Thompson	260	29.1R	
	4,360,652	11/23/82	Dohany	526	210	
	4,370,376	1/25/83	Gangal et al.	428	241	
	4,510,282	4/9/85	Goll	524	337	
	4,514,537	4/30/85	Cavanaugh	524	265	
	4,526,930	7/2/85	Keogh	525	105	
	4,579,636	4/1/86	Inoue et al.	522	99	
	4,771,095	9/13/88	Hanisch et al.	524	437	
	4,946,889	8/7/90	Nishioka	524	544	
	5,003,008	3/26/91	Kobayashi	525	104	
	5,101,565	4/7/92	Trankiem	30	346.54	
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27	5[1993]-170909	7/9/93	Japan	C08G	77/06	Yes
27	8[1996]-170045	7/2/96	Japan	C09D	127/16	Yes
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	9[1997]-165490	6/24/97	Japan	C08L	51/06	Yes
	EP 0 631 999	1/4/95	Europe	C04B	41/49	
	EP 0 736 583	10/9/96	Europe	C09D	127/12	
	JP 07-018214	1/20/95	Japan	C09D	127/16	Yes (JPO Computer Translation)
	JP 58065711	4/19/83	Japan	C08F	14/22	Abstract
	JP 6-322313	11/22/94	Japan	C09D	143/04	Yes
	WO 95/085582	3/3/95	WIPO	C08F	259/08	Yes
	WO 96/06887	3/7/96	WIPO	C08L	27/16	Yes
	WO 97/07155	2/2/97	WIPO	C08G	65/22	Yes
	WO 97/12936	4/10/97	WIPO	C08L	43/04	
	WO 97/15624	5/1/97	WIPO	C08L	43/04	
	WO 98/10724	3/19/98	WIPO	A61F	13/15	
	WO 98/14489	4/9/98	WIPO	C08F	14/06	
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27	Chen et al. "Coatosil™ 1706 a new Silane Monomer for Crosslinking", OSi Specialties A Witco Company, 1996.
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	U.S. Patent Application No. 10/074,333, filed February 12, 2002.
266	U.S. Patent Application entitled: "Crosslinkable Aqueous Fluoropolymer Based Dispersions", claiming priority from U.S. Provisional Patent Application No. 60,143,663, filed 7/14/99, 46 pages.
EXAMINER <i>TLG YCB</i>	
DATE CONSIDERED <i>10-28-03</i>	

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